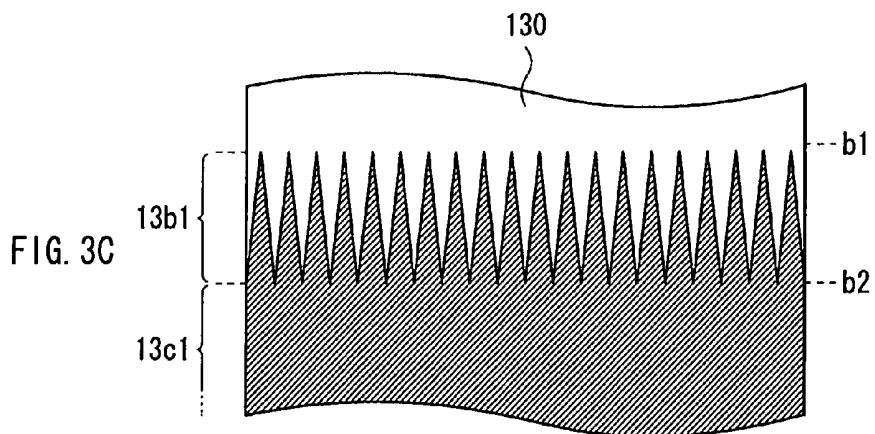
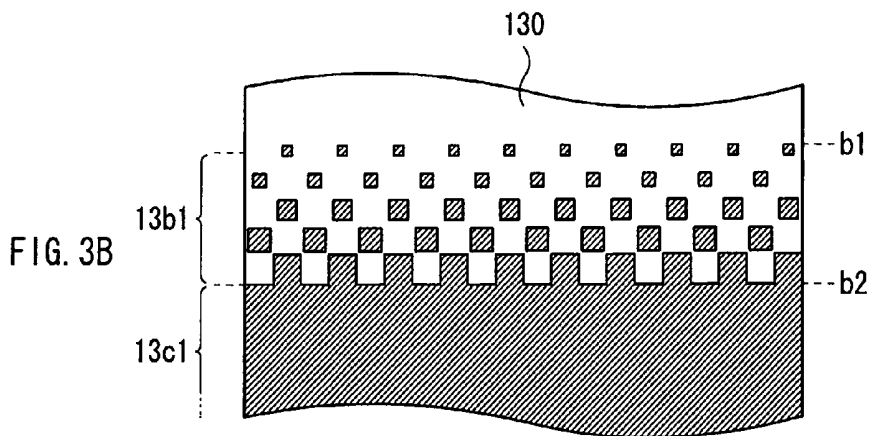
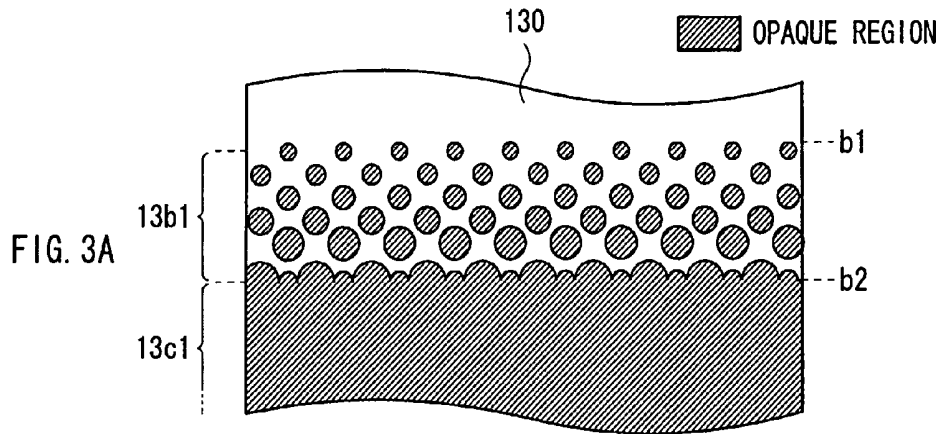


FIG. 2



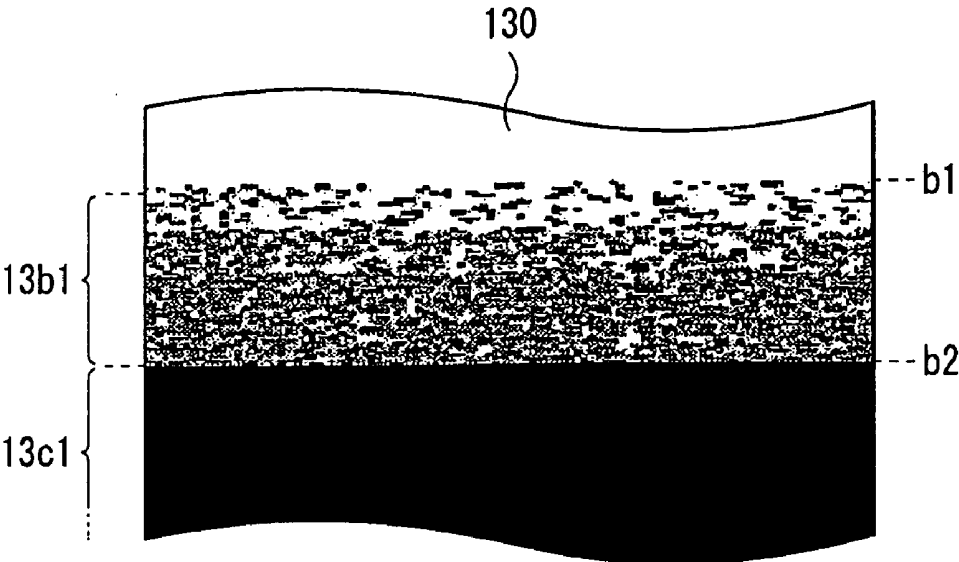
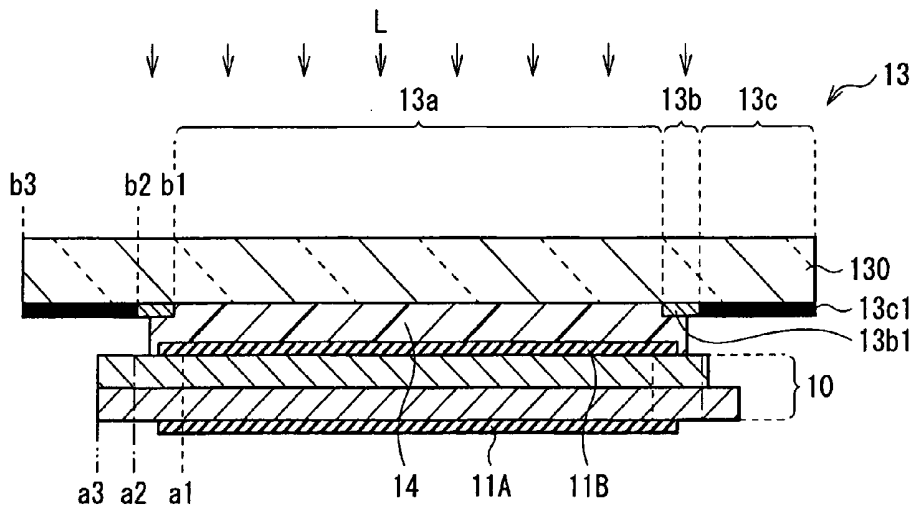
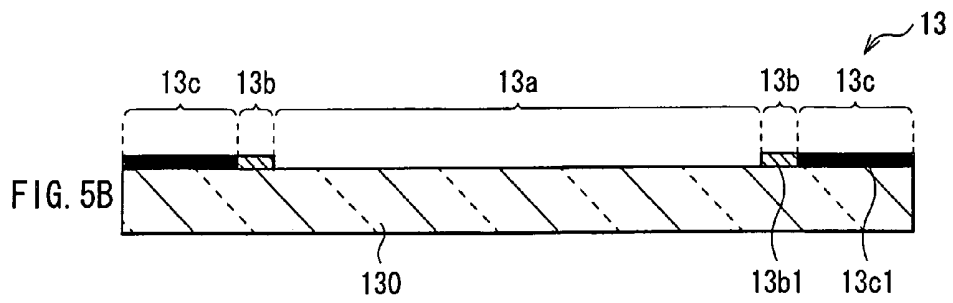
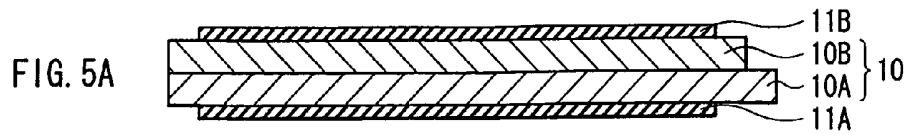


FIG. 4



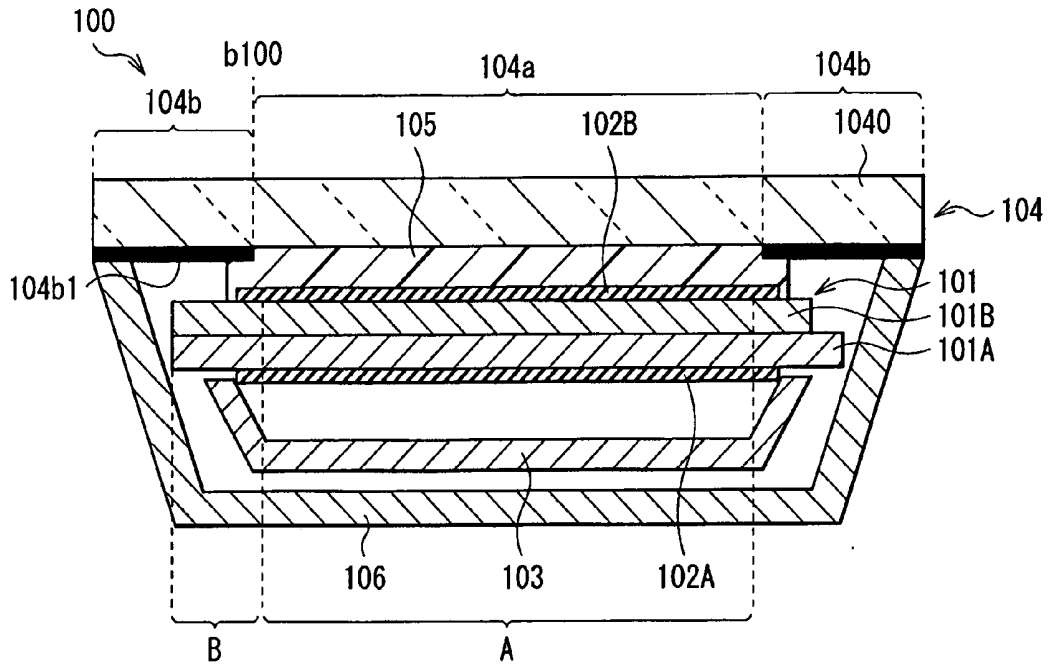


FIG. 7  
RELATED ART

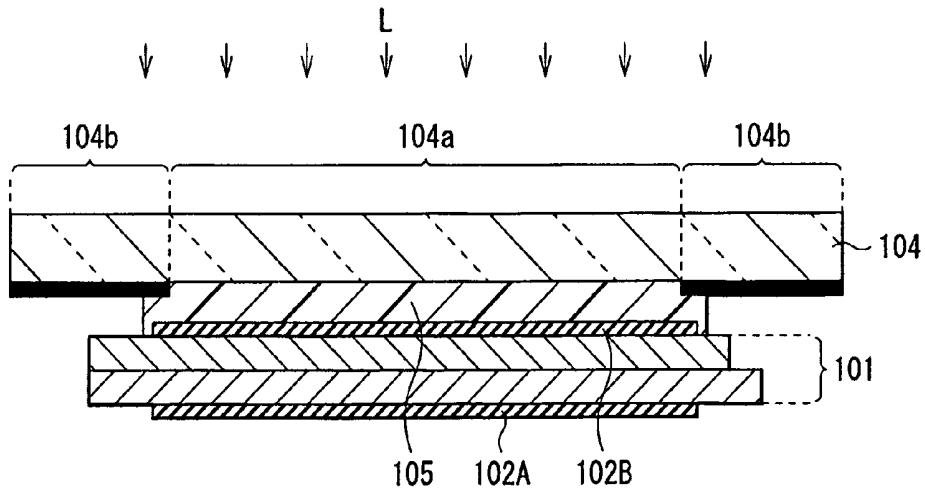


FIG. 8  
RELATED ART

## LIQUID CRYSTAL DISPLAY

### CROSS REFERENCE TO RELATED APPLICATIONS

[0001] The present application claims priority to Japanese Patent Application No. JP 2009-275486 filed in the Japanese Patent Office on Dec. 3, 2009 and Japanese Patent Application No. JP 2010-192008 filed in the Japanese Patent Office on Aug. 30, 2010, the disclosures of which are incorporated herein by reference in their entirety.

### BACKGROUND OF THE INVENTION

[0002] 1. Field of the Invention

[0003] The present invention relates to a liquid crystal display such as a liquid crystal television.

[0004] 2. Description of the Related Art

[0005] In recent years, a liquid crystal display adopting VA (Vertical Alignment) mode is often used as a display monitor for a liquid crystal television, a notebook personal computer, a car navigation system and the like. The liquid crystal display has a liquid crystal display panel in which a liquid crystal layer is sealed between a drive substrate for driving pixels and an opposed substrate provided with a color filter or the like. The liquid crystal display displays an image according to a voltage applied to the liquid crystal display panel.

[0006] It has been known that in such a liquid crystal display, in terms of surface protection and design, a front face plate made of a transparent plastic, glass or the like is provided on the front face of the foregoing liquid crystal display panel (display face side) (for example, see Japanese Unexamined Patent Application Publication Nos. 3-204616, 6-337411, 2005-55641, 2008-281997, and 2008-241728). Japanese Unexamined Patent Application Publication No. 3-204616 proposes to insert a transparent material with the adjusted refractive index between the front face plate and a liquid crystal display panel for preventing image lowering due to interface reflection. Further, Japanese Unexamined Patent Application Publication Nos. 6-337411, 2005-55641, and 2008-281997 uses, as such a transparent material, for example, a liquid, a gel sheet, an adhesive sheet, a light curing resin or the like.

[0007] For example, of the foregoing transparent materials, in the case where the light curing resin is used, after the light curing resin is sandwiched between the liquid crystal display panel and the front face plate, the resin material may be cured by performing light irradiation from the front face plate side. By using the light curing resin, leakage or the like is hardly generated compared to a case using the liquid material. In addition, dust and air bubbles are hardly mixed in manufacturing compared to a case using the adhesive sheet. Further, the liquid crystal display panel and the front face plate are able to be bonded to each other without being affected by strain of the liquid crystal display panel and the front face plate, a step structure or the like.

[0008] Meanwhile, in the front face plate, in some cases, light shielding is provided for a region corresponding to a non-display area (frame section) of the liquid crystal display panel in terms of image improvement and design. Specifically, a light shielding section is formed by evaporation, printing or the like of a light shielding material to a frame-like

region along the rim of the front face plate, or bonding an opaque sheet material with the frame-like region along the rim of the front face plate.

### SUMMARY OF THE INVENTION

[0009] However, in the case where a resin layer made of the light shielding resin is inserted between the front face plate and the liquid crystal display panel, and the foregoing frame-like light shielding section is formed on the front face plate, the following defects are generated. That is, in this case, in the manufacturing process, the resin material is cured by performing light irradiation from the front face plate side on which the light shielding section is formed. Thus, in some cases, frame-like unevenness is generated around the display region after irradiation. It is caused by a fact that an uncured resin material remains in the region corresponding to the light shielding section of the front face plate of the resin layer, and stress balance between the uncured resin material and a cured resin is lost. Thereby, a cell gap around the display region (thickness of the liquid crystal display panel) is changed, and frame-like unevenness is caused. Such unevenness as display unevenness is significantly shown, in particular, when a black screen is observed in a diagonal direction, resulting in lowering of display quality.

[0010] A technique to cure a resin on the rear side of the light shielding section of the front face plate by other curing means by giving thermal curing characteristics or moisture curing characteristics to such a light curing resin has been proposed (see Japanese Unexamined Patent Application Publication No. 2008-241728). However, in such a technique, a curing step is added and the number of equipments is increased. In addition, due to mechanical characteristic difference between the light-cured resin part and the resin part cured by other means (thermal curing or moisture curing), unevenness is generated as a result. Thus, such a technique has not solved the foregoing disadvantages.

[0011] In view of the foregoing, in the invention, it is desirable to provide a liquid crystal display in which a plate-like member having a light shielding section is provided on the panel display side with a light curing resin in between, and display unevenness around the display region is able to be inhibited.

[0012] In accordance with an aspect of the invention, a liquid crystal display device ("LCD") is provided. Such LCD may comprise a front face plate having a first section, a second section, and a third section, the first section being a light transmissive section and the second section being a light shielding section. The third section may be arranged between the first section and the second section, and the third section may have a transmittance value which is lower than that of the first section and higher than that of the second section.

[0013] The third section may include a number of opaque regions, each opaque region having a predetermined shape. The ratio of an area occupied by the number of opaque regions to a total area of the third section may gradually increase from a side of the third section which adjoins the first section to an opposite side of the third section which adjoins the second section.

[0014] The predetermined shape of the opaque regions may be circular, square, or triangular. If the predetermined shape of the opaque regions is circular or square, the opaque regions may gradually increase in size from a side of the third section which adjoins the first section to an opposite side of the third section which adjoins the second section. When the opaque

regions are circular, a diameter of each circular shape may increase from approximately 0.7 mm to approximately 1.2 mm and when the opaque regions are square a side of each square shape may increase from approximately 0.5 mm to approximately 1.0 mm. When the predetermined shape of the opaque regions is triangular, each triangular shape may have a bottom width of approximately 1.5 mm and a height of approximately 4 mm.

**[0015]** The front face plate may include a display region and an outer region outside of the display region, in which at least a substantial portion of the first section is in the display region and an entire portion of the second section and an entire portion of the third section are in the outer region. A liquid crystal display panel may be arranged to be substantially parallel to the front face plate such that the liquid crystal display panel has a plurality of pixels arranged therein, which are aligned with the display region. The second section and the third section may be located on a side of the front face plate which faces the liquid crystal display panel.

**[0016]** A light curing resin layer may be positioned between the front face plate and the liquid crystal display panel such that an entire surface of the first section contacts the resin layer, at least a portion of a surface of the third section contacts the resin layer, and the second section is located entirely away from the resin layer so as to avoid contact thereof.

**[0017]** The first section may have a rectangular shape, the third section may be formed outside a perimeter of the rectangular shaped first section, and the second section may be formed outside a perimeter of the third section.

**[0018]** In accordance with another aspect of the invention, a method for forming a front face plate assembly of an LCD in which the front face plate assembly has a display side and a non-display side opposite the display side is provided. Such method may comprise fabricating a second section that is a light shielding section on the non-display side of the front face plate assembly. A third section may be fabricated on the non-display side such that the second section borders the third section and the third section borders a first section, the first section being a transmissive section. The third section may have a transmittance value lower than that of the first section and higher than that of the second section. A resin layer may be fabricated on the non-display side of the front face plate assembly. A liquid crystal display panel may be fabricated on the resin layer, and the resin layer may be cured.

**[0019]** The resin layer may be cured by irradiating light from a position affording the display side of the front face plate assembly. The light may travel through the first section and the third section so as to impact the resin layer, in which the light is partially absorbed by the third section. In one embodiment, the light irradiated may be between approximately 1500 mJ/cm<sup>2</sup> to approximately 15000 mJ/cm<sup>2</sup>.

#### BRIEF DESCRIPTION OF THE DRAWINGS

**[0020]** FIG. 1 is a cross sectional view illustrating a configuration of a liquid crystal display according to a first embodiment of the invention.

**[0021]** FIG. 2 is a plan view illustrating a structure of the front face plate illustrated in FIG. 1.

**[0022]** FIGS. 3A to 3C are an example of a planar structure of the front face plate illustrated in FIG. 1.

**[0023]** FIG. 4 is another example of a planar structure of the front face plate illustrated in FIG. 1.

**[0024]** FIGS. 5A and 5B are cross sectional views illustrating part of a method of manufacturing the liquid crystal display illustrated in FIG. 1.

**[0025]** FIG. 6 is a cross sectional view illustrating a step following FIGS. 5A and 5B.

**[0026]** FIG. 7 is a cross sectional view illustrating a configuration of a liquid crystal display according to a comparative example.

**[0027]** FIG. 8 is a cross sectional view illustrating part of a method of manufacturing the liquid crystal display illustrated in FIG. 7.

#### DETAILED DESCRIPTION OF THE PREFERRED EMBODIMENT

**[0028]** An embodiment of the invention will be hereinafter described in detail with reference to the drawings. The description will be given in the following order:

**[0029]** 1. Embodiment (example that a half-transmissive section is provided in a front face plate)

**[0030]** 2. Examples

#### Embodiment

##### Configuration of a Liquid Crystal Display 1

**[0031]** FIG. 1 is a cross sectional view illustrating a schematic structure of a liquid crystal display 1 according to an embodiment of the invention. FIG. 2 is a plan view illustrating a structure of a front face plate. The liquid crystal display 1 is, for example, an active matrix type display unit in which video display is performed for every pixel based on a video signal transmitted from a data driver (not illustrated) by a drive signal supplied from a gate driver (not illustrated).

**[0032]** The liquid crystal display 1 includes a backlight unit 12 on the rear face side (light incident side) of a liquid crystal display panel 10 and a front face plate 13 (plate-like member) on the display side (light emitting side), respectively. The liquid crystal display panel 10 and the backlight unit 12 are arranged in a package member 15. Between the liquid crystal display panel 10 and the front face plate 13, a light curing resin layer 14 is provided.

**[0033]** The liquid crystal display panel 10 is intended to perform video display based on illumination light from the backlight unit 12. In the liquid crystal display panel 10, a liquid crystal layer (not illustrated) is sealed between a drive substrate 10A and an opposed substrate 10B. Polarizing plates 11A and 11B are bonded to outside faces of the drive substrate 10A and the opposed substrate 10B. In the drive substrate 10A, a TFT (Thin Film Transistor) for driving each pixel is arranged on, for example, a glass substrate, and a drive circuit for supplying a video signal or the like to each pixel, a wiring substrate for connecting with outside and the like are provided. In the opposed substrate 10B, each color filter (not illustrated) composed of three primary colors (R, G, and B) is formed for every pixel on, for example, a glass substrate. As the liquid crystal layer, for example, a layer containing a nematic liquid crystal such as VA (vertical alignment) mode, TN (Twisted Nematic) mode, and IPS (In Plane Switching) mode is used. The drive substrate 10A and the opposed substrate 10B are not necessarily provided in this order. Further, the color filter is not necessarily provided. Otherwise, the color filter may be provided in the drive substrate 10A instead of in the opposed substrate 10B. Further, as the drive device, a device other than the TFT may be used.

[0034] In the liquid crystal display panel 10, a region around a display region A (rectangle region surrounded by border line a1) is a non-display region B (frame-like region outside of the border line a1). In the display region A, a plurality of pixels are arranged in a state of matrix. In the non-display region B, the foregoing drive circuit for driving each pixel, the foregoing wiring substrate for connecting with outside and the like are arranged. Further, the non-display region B includes a light shielding region (frame-like region that is outside of the border line a1 and inside of border line a2), and a non-light shielding region (frame-like region that is outside of the border line a2 and inside of panel edge a3).

[0035] The backlight unit 12 is intended to illuminate the liquid crystal display panel 10 from the rear face thereof directly or through an optical member such as a light guide plate with the use of, for example, a fluorescent bulb such as a CCFL (Cold Cathode Fluorescent Lamp), an LED (Light Emitting Diode) or the like as a light source.

#### Structure of the Front Face Plate 13

[0036] The front face plate 13 is provided for the purpose of surface protection and design improvement of the liquid crystal display panel 10. The base material of the front face plate 13 is a transparent substrate 130 made of, for example, glass, plastic or the like. Examples of plastic include acryl and polycarbonate. The outside dimensions of the front face plate 13 are larger than the outside dimensions of the liquid crystal display panel 10. An edge of the front face plate 13 (front face plate edge b3) is extended outside than the edge of the liquid crystal display panel 10 (panel edge a3) by, for example, about from 5 mm to 100 mm both inclusive. However, in particular, for the purpose of a large display, in terms of dimension stability, a glass material is desirably used. Further, on the surface on the observation side or display side of the front face plate 13, non-reflecting process or low reflecting process is preferably provided. The thickness of the transparent substrate 130 is, for example, from 0.2 mm to 5.0 mm both inclusive.

[0037] In the front face plate 13, the rectangle region corresponding to the display region A of the liquid crystal display panel 10 is a transmissive section, which may be considered a first section, 13a for transmitting display light. The region around the transmissive section 13a, that is, the frame-like region approximately corresponding to the non-display region B of the liquid crystal display panel 10 is a light shielding section, which may be considered a second section, 13c. The light shielding section 13c is formed on the front face plate 13 for the purpose of improving image quality and design.

[0038] In this embodiment, in the front face plate 13, a half-transmissive section, which may be considered a third section, 13b with the light transmittance that is lower than that of the transmissive section 13a and higher than that of the light shielding section 13c is formed in the region between the transmissive section 13a and the light shielding section 13c. In other words, the frame-like half-transmissive section 13b is provided to surround the rectangle transmissive section 13a, and the frame-like light shielding section 13c is provided to surround the half-transmissive section 13b. The transmissive section 13a is composed of the transparent substrate 130 itself of the front face plate 13. The light shielding section 13c is obtained by forming a light shielding layer 13c1 on one face of the transparent substrate 130, which may be on a non-display side (in this case, face on the light curing resin layer

14 side). The half-transmissive section 13b is obtained by forming a half-transmissive layer 13b1 on one face of the transparent substrate 130, which may also be on the non-display side (in this case, face on the light curing resin layer 14 side). The display side of the front face plate 13 may be opposite the non-display side.

[0039] FIGS. 3A to 3C illustrate planar structures in the vicinity of edges b1 and b2 of the half-transmissive layer 13b1 on the transparent substrate 130. As illustrated in FIGS. 3A to 3C, in the light shielding layer 13c1, the whole area in the light shielding layer 13c1 on the transparent substrate 130 is an opaque region. In the half-transmissive layer 13b1, a selective region in the half-transmissive layer 13b1 on the transparent substrate 130 is an opaque region and the other region is a transparent region. The opaque region in the half-transmissive layer 13b1 and the light shielding layer 13c1 is obtained by forming an opaque material such as carbon black, a metal, and a pigment having a film thickness from 0.1 μm to 100 μm. Meanwhile, the transparent region in the half-transmissive layer 13b1 is a region composed of the transparent substrate 130 itself. In the half-transmissive section 13b having the half-transmissive layer 13b1 exhibits half transmissive characteristics since such an opaque region and such a transparent region coexist in the plane, and the light transmittance thereof corresponds to the ratio occupied by the opaque region in the whole half-transmissive section 13b (opaque region/(transparent region+opaque region). The light transmittance of the half-transmissive section 13b may be uniform (constant) in the half-transmissive section 13b, or may be changed in the half-transmissive section 13b as will be described below.

[0040] Specifically, in the half-transmissive layer 13b1, for example, a plurality of circular opaque regions are formed in a repeated pattern, and the size of each circle is gradually increased from the edge b1 toward the edge b2, that is, from the transmissive section 13a side to the light shielding section 13c side (FIG. 3A). In other words, the ratio occupied by the opaque region in the whole half-transmissive section 13b is gradually increased from the transmissive section 13a side to the light shielding section 13c side. Thereby, the light transmittance is gradually decreased from the transmissive section 13a side to the light shielding section 13c side.

[0041] However, the planar shape of the opaque region in the half-transmissive layer 13b1 is not limited to the foregoing circular shape, but may be the square shape as illustrated in FIG. 3B in which, for example, the opaque region and the transmissive region are included in a staggered pattern. Further, the planar shape is not limited to the square shape, but may be other polygonal shape such as a triangle shape and a rectangle shape. Otherwise, as illustrated in FIG. 3C, the opaque region in the half-transmissive layer 13b1 may be saw-like shape in which isosceles triangles are formed in repeating fashion. With such a structure, the light transmittance is able to be gradually decreased from the transmissive section 13a side to the light shielding section 13c side as well. Further, the planar shape of the opaque region in the half-transmissive layer 13b1 is not necessarily in a repeating pattern. As illustrated in FIG. 4, the half-transmissive layer 13b1 may have a planar structure in which a plurality of minute opaque regions are dispersed and arranged so that the light transmittance is gradually decreased from the transmissive section 13a side to the light shielding section 13c side. In FIG. 4, the section colored black is the opaque region.

**[0042]** Further, the opaque region may be formed in a regular arrangement, but may be formed in an irregular (random) arrangement. Further, each planar shape of the respective opaque regions is not necessarily identical with each other, but may be different from each other. However, in any case, it is desirable that the ratio of the foregoing opaque region is smaller on the transmissive section **13a** side and is larger on the light shielding section **13c** side. In other words, it is desirable that the light transmittance in the half-transmissive section **13b** is higher on the transmissive section **13a** side and is lower on the light shielding section **13c** side. Further, it is more desirable that in the half-transmissive section **13b**, the ratio of the foregoing opaque region is gradually increased, the light transmittance is gradually decreased from the transmissive section **13a** side to the light shielding section **13c** side as in this embodiment. Thereby, stress balance between the uncured resin and the cured resin is easily retained favorably.

**[0043]** As illustrated in FIG. 1 and FIG. 2, the foregoing edge **b1** on the transmissive section **13a** side of the half-transmissive section **13b** is arranged outside of the border line **a1** (on the non-display region B side). Meanwhile, the edge **b2** on the light shielding section **13c** side of the half-transmissive section **13b** is arranged inside of the border line **a2** (on the light shielding region side). That is, in this embodiment, the half-transmissive section **13b** is provided in the light shielding region in the non-display region B. Due to such arrangement, light from the backlight unit **12** is able to be prevented from being leaked through the half-transmissive section **13b**. However, the position of the edge **b2** of the half-transmissive section **13b** is not particularly limited, and may be arranged outside of the border line **a2** (non-light shielding region side). For example, in the non-light shielding region in the non-display region B (outside of the border line **a2**), light shielding is enabled by using other light shielding member. In such a case, the edge **b2** of the half-transmissive section **13b** may be in the non-light shielding region. Further, the edge **b1** may be overlapped with the border line **a1**. Further, the planar dimensions of the half-transmissive section **13b** may be the same as the planar dimensions of the light shielding region in the non-display region B (the edge **b1** may be overlapped with the border line **a1**, and the edge **b2** may be overlapped with the border line **a2** at the same time).

#### Structure of the Light Curing Resin Layer **14**

**[0044]** The light curing resin layer **14** has a function to inhibit interface reflection between the liquid crystal display panel **10** and the front face plate **13**. For example, the light curing resin layer **14** is made of a silicone resin, an epoxy resin, an acryl resin or the like that is cured by ultraviolet light or visible light, and is desirably made of the acryl resin. As the acryl resin, an oligomer, an acryl monomer, a resin composition of matter containing a photopolymerization initiator, a plasticizer and the like are desirable. Examples of oligomer include polyurethane acrylate, polybutadiene acrylate, polyester acrylate, and epoxy acrylate. As an acryl monomer, for example, a monofunctional acryl monomer is desirably used.

**[0045]** In the light curing resin layer **14**, the refractive index is desirably almost equal to the refractive index of the front face plate **13** (for example, from 1.4 to 1.6 both inclusive). Thereby, interface reflection is able to be more effectively inhibited. Further, in terms of manufacturing process, the viscosity of the resin before curing in the light curing resin layer **14** is desirably from 100 to 4000 mPa·s both inclusive. Further, to inhibit display unevenness, the curing shrinkage

ratio in curing the resin in the light curing resin layer **14** is desirably 4% or less. The storage elastic modulus at 25 deg C. after curing the resin is desirably  $1.0 \times 10^6$  Pa or less.

**[0046]** The thickness of the light curing resin layer **14** is desirably from 20  $\mu\text{m}$  to 5 mm both inclusive, and more desirably from 20  $\mu\text{m}$  to 500  $\mu\text{m}$  both inclusive. If the thickness of the light curing resin layer **14** is smaller than 20  $\mu\text{m}$ , adhesive strength is decreased, or manufacturing characteristics are deteriorated. Meanwhile, if the thickness is larger than 500  $\mu\text{m}$ , image depth feel stands out, design quality is lowered, cost is increased since the usage amount of the resin material is increased, and the weight of the whole unit is increased.

#### Method of Manufacturing the Liquid Crystal Display **1**

**[0047]** FIG. 5A to FIG. 6 illustrate part of a method of manufacturing the liquid crystal display **1** in order of steps. The liquid crystal display **1** as described above is able to be manufactured, for example, as follows.

**[0048]** First, as illustrated in FIG. 5A, the liquid crystal display panel **10** is formed. That is, the drive substrate **10A** in which the TFT, the drive circuit and the like are arranged and the opposed substrate **10B** having the color filter are bonded to the liquid crystal layer (not illustrated) in between. After that, the polarizing plates **11A** and **11B** are bonded to the outside faces of the drive substrate **10A** and the opposed substrate **10B**.

**[0049]** Meanwhile, as illustrated in FIG. 5B, the opaque material as described above is, for example, evaporated or printed on a given frame-like region on the transparent substrate **130**. Thereby, the front face plate **13** having the half-transmissive layer **13b1** and the light shielding layer **13c1** is formed. At this time, in the light shielding layer **13c1**, the opaque material is evaporated or printed on the transparent substrate **130** in solid fashion, and thereby the whole area in the light shielding layer **13c1** becomes the opaque region.

**[0050]** Meanwhile, in the half-transmissive layer **13b1**, the opaque material is evaporated or printed on a selective region on the transparent substrate **130**, and thereby the selective region in the half-transmissive layer **13b1** becomes the opaque region, and the other region becomes the transparent region. In the case where the half-transmissive layer **13b1** is formed by evaporation, as an evaporation mask, a mask having an aperture corresponding to the repeating pattern of the opaque region as described above may be used. Otherwise, in the case where the half-transmissive layer **13b1** is formed by printing, a printing plate corresponding to the repeating pattern of the opaque region as described above may be used by, for example, screen printing or offset printing. The half-transmissive layer **13b1** and the light shielding layer **13c1** may be directly formed on the transparent substrate **130** as described above. Otherwise, it is possible that the light shielding layer **13c1** and the half-transmissive layer **13b1** are previously formed on other transparent sheet, and the sheet is bonded to the transparent substrate **130**.

**[0051]** On the surface of the observation side of the front face plate **13**, non-reflecting process or low reflecting process is preferably provided. Such a process is able to be performed by, for example, evaporating a non-reflecting material or a low reflecting material or coating with the same, or bonding a non-reflecting film, a low reflecting film or the like.

**[0052]** Subsequently, as illustrated in FIG. 6, the liquid crystal display panel **10** and the front face plate **13** formed as above are layered with the light curing resin layer **14** in

between. From the front face plate **13** side, light *L* in a wavelength region by which the resin material in the light curing resin layer **14** is cured, such as ultraviolet light and visible light is irradiated. Specifically, light with photosensitive wavelength in a photo initiator contained in the light curing resin layer **14** may be used. However, in terms of productivity, a lamp having the light emitting center of 365 nm or 405 nm, an LED having such a light emitting wavelength or the like is preferably used. Further, the illuminance and the light amount of the light *L* may be set according to the composition, the thickness and the like of the resin material used for the light curing resin layer **14**. However, it is desirable that the accumulated light amount is set to from 1500 to 15000 mJ/cm<sup>2</sup> both inclusive, and the luminance is set to from 10 to 500 mW/cm<sup>2</sup> both inclusive, respectively. Accordingly, the front face plate **13** is bonded to the liquid crystal display panel **10** with the light curing resin layer **14** in between.

[0053] Finally, the liquid crystal display panel **10** and the front face plate **13** bonded to each other as described above are arranged in the package member **15** together with the backlight unit **12**. Thereby, the liquid crystal display **1** illustrated in FIG. 1 is completed.

#### Action and Effect of the Liquid Crystal Display 1

[0054] In the liquid crystal display **1**, in the case where light enters the liquid crystal display panel **10** from the backlight unit **12**, the incident light passes through the polarizing plate **11A**, and is subsequently transmitted through a liquid crystal layer (not illustrated) while being modulated for every pixel based on a video voltage applied between the drive substrate **10A** and the opposed substrate **10B**. The light transmitted through the liquid crystal layer passes through the opposed substrate **10B** having the color filter (not illustrated). Thereby, the light is extracted outside of the polarizing plate **11B** as color display light.

[0055] FIG. 7 and FIG. 8 illustrate a cross sectional configuration of a liquid crystal display **100** according to a comparative example and part of a method of manufacturing the same. The liquid crystal display **100** includes a backlight unit **103** on the rear face side of a liquid crystal display panel **101** and a front face plate **104** on the display side, respectively. The liquid crystal display panel **101** and the backlight unit **103** are arranged in a package member **106**. Between the liquid crystal display panel **101** and the front face plate **104**, a light curing resin layer **105** is provided. In the liquid crystal display panel **101**, a liquid crystal layer (not illustrated) is sealed between a drive substrate **101A** and an opposed substrate **101B**. Polarizing plates **102A** and **102B** are bonded to outside faces of the drive substrate **101A** and the opposed substrate **101B**. In the liquid crystal display panel **100**, in the front face plate **104**, a region corresponding to the display region A of the liquid crystal display panel is a transmissive section **104a**, and a light shielding section **104b** is provided correspondingly to the non-display region B. In the light shielding section **104b**, a light shielding layer **104b1** is formed on one face of a transparent substrate **1040**. An edge **100** on the transmissive section **104a** side of the light shielding section **104b** is arranged in the non-display region B and in the vicinity of the boundary between the display region A and the non-display region B.

[0056] In the manufacturing process of the liquid crystal display **100** of comparative example, as illustrated in FIG. 8, the light shielding section **104b** is provided in the region corresponding to the non-display region B of the front face

plate **104**. Thus, when light is irradiated from the front face plate **104** side, the following defect is generated. That is, when light is irradiated from the front face plate **104** side having such a light shielding section **104b**, of the light curing resin layer **105**, in the region on the rear side of the light shielding section **104b**, light is not sufficiently obtained, and an uncured resin remains. That is, in the light curing resin layer **105** after irradiating light, the section corresponding to the transmissive section **104a** of the front face plate **104** is cured, while the section corresponding to the light shielding section **104b** is not cured. Thus, around the display region A, stress balance in the light curing resin layer **105** is lost. Therefore, around the display region A, the thickness of the liquid crystal display panel **101** is changed, and frame-like unevenness is generated. Such thickness unevenness is significantly shown in the case where, in particular, a black screen is observed in the diagonal direction, and may be a factor to lower display quality.

[0057] Meanwhile, in this embodiment, in the manufacturing process, light is irradiated from the front face plate **13** side having the light shielding section **13c** and thereby the resin material of the light curing resin layer **14** is cured. The half-transmissive section **13b** is provided between the transmissive section **13a** and the light shielding section **13c** of the front face plate **13**. Thereby, in the light curing resin layer **14**, in the vicinity of the boundary between the display region A and the non-display region B (around the display region A), the ratio of the uncured resin material is decreased. Further, rapid resin characteristic change between the cured section and the uncured section of the resin material is inhibited. Thus, stress balance around the display region A is favorably retained, and frame-like unevenness is inhibited from being generated in the thickness of the liquid crystal display panel **10**. Further, light shielding characteristics in the front face plate **13** is not ruined largely in the region around the display region A.

[0058] As described above, in this embodiment, the front face plate **13** is provided on the display side of the liquid crystal display panel **10** with the light curing resin layer **14** in between. In the front face plate **13**, the light shielding section **13c** is provided correspondingly to the non-display region B. In addition, the half-transmissive section **13b** with the light transmittance that is lower than that of the transmissive section **13a** and higher than that of the light shielding section **13c** is provided in the region between the transmissive section **13a** and the light shielding section **13c**. Thereby, unevenness is inhibited from being generated in the thickness of the liquid crystal display panel **10** without largely ruining light shielding characteristics in the region around the display region A. Thus, it is possible that the front face plate **13** having the light shielding section **13c** is provided on the display side of the liquid crystal display panel **10** with the light curing resin layer **14** in between, and display unevenness in the region around the display region is inhibited from being generated. Thereby, display quality is improved, and high quality video display is able to be realized.

#### EXAMPLES

[0059] Next, a description will be given of the liquid crystal display of the invention with reference to specific examples (Examples 1 to 4).

##### Example 1

[0060] As Example 1, the front face plate **13** was layered on the transmissive VA type liquid crystal display panel **10** hav-

ing a screen size of 40, 46, 52, or 60 inches as diagonal dimensions with the light curing resin layer **14** made of an ultraviolet curing resin having a thickness of 200  $\mu\text{m}$  in between. After that, ultraviolet was irradiated from the front face plate **13** side. At that time, as an irradiation light source, a metal halide lamp with illuminance of 100  $\text{mW}/\text{cm}^2$  that mainly emits light with 365 nm was used, and accumulated amount of 5000  $\text{mJ}/\text{cm}^2$  was irradiated. The front face plate **13** was larger than the liquid crystal display panel by about 5 cm vertically and horizontally. As the ultraviolet curing resin, an acryl resin having the curing shrinkage ratio of 2.8% and the storage elastic modulus at 25 deg C. after curing the resin of  $5.0 \cdot 10^5$  Pa was used. As the front face plate **13**, a plate in which the light shielding section **13c** and the half-transmissive section **13b** were formed on the transparent substrate **130** made of glass having a plate thickness of 2.5 mm was used. The dimensions of the half-transmissive section **13b** were the same as those of the light shielding region in the non-display region B of the liquid crystal display panel **10**. Circular opaque regions having a diameter of 1 mm were pattern-formed, and thereby the ratio occupied by the opaque region in the whole half-transmissive section **13b** was 50% uniformly in the plane.

#### Example 2

[0061] As Example 2, in the same manner as that of the foregoing Example 1, the front face plate **13** was layered on the transmissive VA type liquid crystal display panel **10** having a screen size of 40, 46, 52, or 60 inches with the light curing resin layer **14** made of an ultraviolet curing resin having a thickness of 200  $\mu\text{m}$  in between. After that, ultraviolet was irradiated from the front face plate **13** side. At that time, the ultraviolet irradiation conditions, the outer dimensions of the front face plate **13**, the material and the plate thickness of the transparent substrate **130**, the ultraviolet curing resin material, and the dimensions of the half-transmissive section **13b** were similar to those of the foregoing Example 1. However, in Example 2, circular opaque regions having a diameter from 0.6 mm to 1.2 mm both inclusive were pattern-formed from inside to outside, and thereby the ratio of the foregoing opaque region was changed between the region on the transmissive section **13a** side and the region on the light shielding section **13c** side. Specifically, the ratio of the foregoing opaque region was 30% in the region on the transmissive section **13a** side and 80% in the region on the light shielding section **13c** side.

#### Example 3

[0062] As Example 3, in the same manner as that of the foregoing Example 2, the front face plate **13** was layered on the transmissive VA type liquid crystal display panel **10** having a screen size of 40, 46, 52, or 60 inches with the light curing resin layer **14** made of an ultraviolet curing resin having a thickness of 200  $\mu\text{m}$  in between. After that, ultraviolet was irradiated from the front face plate **13** side. At that time, the ultraviolet irradiation conditions, the outer dimensions of the front face plate **13**, the material and the plate thickness of the transparent substrate **130**, the dimensions of the half-transmissive section **13b**, the repeating pattern of the opaque region, and the ratio of the opaque region were similar to those of the foregoing Example 2. However, in Example 3, as the ultraviolet curing resin, a resin having the curing

shrinkage ratio of 2.0% and the storage elastic modulus at 25 deg C after curing the resin of  $5.0 \cdot 10^4$  Pa was used.

#### Example 4

[0063] As Example 4, in the same manner as that of the foregoing Example 2, the front face plate **13** was layered on the transmissive liquid crystal display panel **10** having a screen size of 40, 46, 52, or 60 inches with the light curing resin layer **14** made of an ultraviolet curing resin having a thickness of 200  $\mu\text{m}$  in between. After that, ultraviolet was irradiated from the front face plate **13** side. At that time, the ultraviolet irradiation conditions, the outer dimensions of the front face plate **13**, the material and the plate thickness of the transparent substrate **130**, the ultraviolet curing resin material, the dimensions of the half-transmissive section **13b**, the repeating pattern of the opaque region, and the ratio of the opaque region were similar to those of the foregoing Example 2. However, in Example 4, as the liquid crystal display panel **10**, IPS type was used instead of the VA type.

#### Comparative Example

[0064] As a comparative example of the foregoing Examples 1 to 4, as illustrated in FIG. 8, the front face plate **104** was layered on the liquid crystal display panel **101** with the light curing resin layer **105** in between. After that, ultraviolet was irradiated from the front face plate **104** side. As the liquid crystal display panel **101**, a transmissive VA type liquid crystal display panel having a screen size of 40, 46, 52, or 60 inches was used as in the foregoing Example 1. As the light curing resin layer **105**, an ultraviolet curing resin having a material and a thickness similar to those of the foregoing examples was used. Further, the ultraviolet irradiation conditions, the outer dimensions, the material and the plate thickness of the front face plate **104**, of the transparent substrate **1040** were similar to those of the foregoing examples. However, in comparative example, in the front face plate **104**, a plate in which a half-transmissive section was not provided between the transmissive section **104a** and the light shielding section **104b** was used. The light shielding section **104b** was formed so that the edge **b100** inside of the light shielding section **104b** corresponded with the borderline between the display region A and the non-display region B of the liquid crystal display panel **101**.

[0065] As described above, for Examples 1 to 4 and comparative example, the liquid crystal displays were fabricated, each display image was observed, and presence of display unevenness was evaluated. The result is illustrated in Table 1. As illustrated in Table 1, visual display unevenness was very few in Examples 1 to 4 in which the half-transmissive section **13b** was provided in the front face plate **13**, while display unevenness was generated in comparative example in which the half-transmissive section was not provided. Further, in Examples 2 to 4 in which the light transmittance in the half-transmissive section **13b** was changed, more favorable result was obtained for the following reason. That is, rapid resin characteristics change between the cured section and the uncured section of the resin was effectively inhibited. As described above, it was found that even in the case where the front face plate **13** having the light shielding section **13c** was provided on the display side of the liquid crystal display panel **10** with the light curing resin layer **14** in between, by providing the half-transmissive section **13b** on the front face plate

**13**, a high quality liquid crystal display without display unevenness was able to be provided as well.

TABLE 1

	Example 1	Example 2	Example 3	Example 4	Comparative example 1
40 inches	good	very good	very good	very good	Poor
46 inches	good	very good	very good	very good	Poor
52 inches	good	very good	very good	very good	Poor
60 inches	good	very good	very good	very good	Poor

Very good: Unevenness never viewed

Good: Unevenness slightly viewed but not annoying

Poor: Heavy unevenness viewed and disturbing

**[0066]** While the invention has been described with reference to the embodiment and the modified examples, the invention is not limited to the foregoing embodiment and the like, and various modifications may be made. For example, in the foregoing embodiment and the like, the description has been given of the case that the polarizing plate **11B** on the light emitting side of the liquid crystal display panel **10** is bonded to the surface of the liquid crystal display panel **10** as an example. However, the polarizing plate **11B** may be provided on the observer side surface of the front face plate **13**.

**[0067]** It should be understood by those skilled in the art that various modifications, combinations, sub-combinations and alternations may occur depending on design requirements and other factors insofar as they are within the scope of the appended claims or the equivalents thereof.

**1.** A liquid crystal display device comprising:  
a front face plate having a first section, a second section, and a third section,  
the first section being a light transmissive section and the second section being a light shielding section,  
the third section being arranged between the first section and the second section, and  
the third section having a transmittance value which is lower than that of the first section and higher than that of the second section.

**2.** The liquid crystal display device of claim **1**, in which the third section includes a number of opaque regions, each opaque region having a predetermined shape.

**3.** The liquid crystal display device of claim **2**, in which a ratio of an area occupied by the number of opaque regions to a total area of the third section gradually increases from a side of the third section which adjoins the first section to an opposite side of the third section which adjoins the second section.

**4.** The liquid crystal display device of claim **2**, in which the predetermined shape of the opaque regions is circular, square, or triangular.

**5.** The liquid crystal display device of claim **2**, in which the predetermined shape of the opaque regions is circular or square and in which the opaque regions gradually increase in size from a side of the third section which adjoins the first section to an opposite side of the third section which adjoins the second section.

**6.** The liquid crystal display device of claim **5**, in which when the opaque regions are circular a diameter of each circular shape increases from approximately 0.7 mm to approximately 1.2 mm and when the opaque regions are

square a side of each square shape increases from approximately 0.5 mm to approximately 1.0 mm.

**7.** The liquid crystal display device of claim **2**, in which the predetermined shape of the opaque regions is triangular and each triangular shape has a bottom width of approximately 1.5 mm and a height of approximately 4 mm.

**8.** The liquid crystal display device of claim **1**, in which the front face plate includes a display region and an outer region outside of the display region, in which at least a substantial portion of the first section is in the display region and an entire portion of the second section and an entire portion of the third section are in the outer region.

**9.** The liquid crystal display device of claim **8**, further comprising a liquid crystal display panel arranged to be substantially parallel to the front face plate, said liquid crystal display panel having a plurality of pixels arranged therein which are aligned with the display region.

**10.** The liquid crystal display device of claim **9**, in which the second section and the third section are located on a side of the front face plate which faces the liquid crystal display panel.

**11.** The liquid crystal display device of claim **10**, further comprising a light curing resin layer positioned between the front face plate and the liquid crystal display panel such that an entire surface of the first section contacts the resin layer, at least a portion of a surface of the third section contacts the resin layer, and the second section is located entirely away from the resin layer so as to avoid contact thereof.

**12.** The liquid crystal display device of claim **1**, in which the first section has a rectangular shape, the third section is formed outside a perimeter of the rectangular shaped first section, and the second section is formed outside a perimeter of the third section.

**13.** A method for forming a front face plate assembly of a liquid crystal display device in which the front face plate assembly has a display side and a non-display side opposite the display side, said method comprising:

fabricating a second section that is a light shielding section on the non-display side of the front face plate assembly;  
fabricating a third section on the non-display side such that the second section borders the third section and the third section borders a first section, the first section being a transmissive section, the third section having a transmittance value lower than that of the first section and higher than that of the second section;

fabricating a resin layer on the non-display side of the front face plate assembly;

fabricating a liquid crystal display panel on the resin layer;  
and

curing the resin layer.

**14.** The method of claim **13**, in which an entire surface of the first section contacts the resin layer, at least a portion of a surface of the third section contacts the resin layer, and the second section is located entirely away from the resin layer so as to avoid contact thereof.

**15.** The method of claim **13**, in which the resin layer is cured by irradiating light from a position affronting the display side of the front face plate assembly, the light traveling through the first section and the third section so as to impact the resin layer, in which the light is partially absorbed by the third section.

**16.** The method of claim **13**, in which the third section includes a number of opaque regions, each opaque region having a predetermined shape.

17. The method of claim 16, in which the predetermined shape of the opaque regions is circular, square, or triangular.

18. The method of claim 17, in which a ratio of an area occupied by the number of opaque regions to a total area of the third section gradually increases from a side of the third section which adjoins the first section to an opposite side of the third section which adjoins the second section.

19. The method of claim 16, in which the predetermined shape of the opaque regions is circular or square and in which the opaque regions gradually increase in size from a side of

the third section which adjoins the first section to an opposite side of the third section which adjoins the second section.

20. The method of claim 19, in which when the opaque regions are circular a diameter of each circular shape increases from approximately 0.7 mm to approximately 1.2 mm and when the opaque regions are square a side of each square shape increases from approximately 0.5 mm to approximately 1.0 mm.

\* \* \* \* \*

专利名称(译)	液晶显示器		
公开(公告)号	<a href="#">US20110134378A1</a>	公开(公告)日	2011-06-09
申请号	US12/927823	申请日	2010-11-24
[标]申请(专利权)人(译)	索尼公司		
申请(专利权)人(译)	索尼公司		
当前申请(专利权)人(译)	SATURN Licensing LLC的		
[标]发明人	TSUBOI HISANORI FUJII HIROAKI ARAKI SOYA TERAMOTO RYOICHI SAKUMA TAKESHI NINOMIYA KIYOTAKA UDA NORIO		
发明人	TSUBOI, HISANORI FUJII, HIROAKI ARAKI, SOYA TERAMOTO, RYOICHI SAKUMA, TAKESHI NINOMIYA, KIYOTAKA UDA, NORIO		
IPC分类号	G02F1/1333 B32B37/14		
CPC分类号	G02F1/133308 G02F1/133512 G02F2001/133331 H04N5/65 G02F2202/023 G02F2202/28 G02F2001/133562		
优先权	2009275486 2009-12-03 JP 2010192008 2010-08-30 JP		
其他公开文献	US8379173		
外部链接	<a href="#">Espacenet</a> <a href="#">USPTO</a>		

摘要(译)

公开了一种具有前面板的液晶显示装置，该前面板具有第一部分，第二部分和第三部分。第一部分具有透光部分，第二部分是遮光部分。第三部分可以布置在第一部分和第二部分之间。第三部分的透射率值低于第一部分的透射率值并高于第二部分的透射率值。还公开了一种用于形成液晶显示装置的前面板组件的方法，该前面板组件可包括前面板。

